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Pat. No. 05673832 - 1
Issue Date: 10/28/02

Group ID: B
User ID: ginab

Page 1
KS: 5,080

Warning [Pages Of US References:]

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Warning [Pages Of Foreign References:]

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Page 1

PTOL85b INFO

SERIAL NUMBER FILING DATE

09/165,513 10/02/98

ASSIGNEE DATA PRESENT DATE FEE PAID

Yes 01/29/03

EMAIL ADDRESS

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ATTORNEYS

Type: Firm/First: Middle: Last:

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02 United Module Corporation, Inc.

City: State: Country:

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Text:

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REFERENCES (Page 7) SERIAL NUMBER: 09/165,513
FORM 1449

U.S. REFERENCES

<u>U.S. Pat No.</u>	<u>Date</u>	<u>Patentee</u>	<u>Class</u>	<u>SubClass</u>
<u>5,411,797</u>	<u>05/1995</u>	<u>Davanloo et al.</u>		
<u>5,470,661</u>	<u>11/1995</u>	<u>Bailey et al.</u>		
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No issue date available.

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Park, K.C. et al., +37 Enhancement of Field-Emission Characteristics
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PR Newswire. CeBIT Showcase for Major Advance in Magnetic Disk Storage
Capacity. Feb. 2000 Hanover, Germany. website:
<http://www.prnewswire.com> (Feb. 19, 2000).

***** End of edited forms *****

CHECK LIST

Rule 47 Continuing Data PCT Disclaimer

No Yes No No

Microfiche Appendix CPA tag

No No

Foreign Priority Claimed: No
Acknowledged: No

State Code: MN Country Code:

Text Endorsement: 09165513.100298

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JACKET

<u>SERIAL NUMBER</u>	<u>FILING DATE</u>	<u>CLASS</u>	<u>SUBCLASS</u>	<u>GAU</u>
09/165,513	10/02/98	428	408	1773

FOREIGN PRIORITY
Country Document Number Date

DISCLAIMER

/ /

TITLE

Recording media having protective overcoats of highly tetrahedral
amorphous carbon and methods for their production

MICROFICHE APPENDIX

ASSISTANT EXAMINER:

First: Middle: Last:

PRIMARY EXAMINER:

First: Middle: Last:

Stevan A. Resan

CLAIMS ALLOWED
Total Print

24 1

DRAWINGS
Sheets Figures Print

12 20 Y

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BLUE SLIP INFORMATION

<u>SERIAL NUMBER</u>	<u>CLASS</u>	<u>SUBCLASS</u>	<u>GAU</u>
09/165,513	428	408	1773

<u>INDEP. CLAIMS</u>	<u>TOTAL CLAIMS</u>
1, 21, 23, 24	24

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BLUE SLIP (Page 1)

INTERNATIONAL CLASSIFICATION
Class SubClass

G11B 5/72

CROSS-REFERENCES
Class SubClass

428 694 TC

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TERM EXTENSION

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FIELD OF SEARCH

Class SubClass

428 408;694 TC

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Pat. No. 05673832 - 1
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Page 5

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Firm Townsend and Townsend and Crew LLP

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ASSIGNEES

Code: Firm/First: Middle: Last:

02 United Module Corporation, Inc.

City: State: Country:

San Francisco CA

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OATH

INVENTOR NAME

First: Middle: Last: Signed:

Veerasamy Vijayen Yes

City: Farmington Hills

State: MN ZIP Code: Country: Foreign ZIP:

INVENTOR NAME

OTHER REFERENCE CITATIONS (incl. Author, Title, Date, Pertinent Pages, etc.)

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REFERENCES (Page 2) SERIAL NUMBER: 09/165,513
FORM 892

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REFERENCES (Page 4) SERIAL NUMBER: 09/165,513
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PR Newswire. CeBIT Showcase for Major Advance in Magnetic Disk Storage
Capacity. Feb. 2000 Hanover, Germany. website:
<http://www.prnewswire.com> (Feb. 19, 2000).

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